

Electronically Filed April 17, 2008

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of:	Sang-In LEE, <i>et al.</i>	Confirmation No.:	2947
Serial No.:	10/525,122	Art Unit:	2812
Filed:	March 20, 2006	Examiner:	Roman, Angel
For:	<i>Atomic Layer Deposition of High-k Metal Silicates</i>	Attorney Docket No:	067538-5171-US

PETITION FOR EXTENSION OF TIME UNDER 37 CFR § 1.136(a)

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

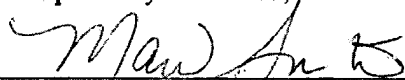
Sir:

It is respectfully requested that the time for response to the Final Office Action dated October 17, 2007 be extended for a period of three-month from January 17, 2008 to April 17, 2008.

The fee for this extension is estimated to be \$1050.00. Please charge the required fee to Morgan, Lewis & Bockius LLP Deposit Account No. 50-0310 (order no. 067538-5171-US).

Date: April 17, 2008

Respectfully submitted,



37,244

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